

**IN THE CLAIMS:**

The following is a complete listing of claims in this application.

17. (currently amended) Device for the injection of gas bubbles into a liquid metal contained in a treatment volume, comprising at least one static injection part made of a material inert to the liquid metal and wettable by the liquid metal, the static part comprising a substantially planar surface without protuberances or discontinuities on which a plurality of orifices is disposed on a substantially planar surface,

the wettable material, and optionally orifice configuration, being selected such that bubbles emitted by the device have a spreading ratio of less than 5.

18. (previously presented) Device according to claim 17, wherein the spreading ratio is less than 3.

19. (previously presented) Device according to claim 17, wherein the spreading ratio is less than 1.5.

20. (previously presented) Device according to claim 19, wherein the liquid metal is aluminum, magnesium or alloys thereof, and the wettable material is a metal or ceramic.

21. (previously presented) Device according to claim 20, wherein the metal is selected from the group consisting of W, Mo, Ti, V, Cr, Fe, steels and alloys thereof.

22. (previously presented) Device according to claim 20, wherein the ceramic is selected from the group consisting of  $TiB_2$ , AlN, BN,  $Al_4C_3$  and  $TiC_{1-x}$ .

23. (previously presented) Device according to claim 20, wherein the ceramic is a nitride or carbide.

Claims 24-25 (canceled).

26. (previously presented) Device according to claim 17, additionally comprising means for regulating gas pressure at

the orifices.

27. (previously presented) Device according to claim 26, wherein the means for regulating comprises a mass flow meter.

28. (previously presented) Device according to claim 26, wherein the means for regulating comprises a porous means introducing a local pressure head loss just upstream of the gas outlet orifice.

29. (previously presented) Device according to claim 17, additionally comprising means for introducing shearing energy to the liquid metal.

30. (previously presented) Device according to claim 29, wherein the means for introducing comprises an ultrasound means or a rotary stirrer means.

31. (previously presented) Device according to claim 17, wherein the orifices are separated from each other by a distance sufficient that the bubbles do not come into contact while they are being formed.

32. (previously presented) Device according to claim 17, wherein the static injection part is made of a plurality of elements assembled together.

33. (previously presented) Device according to claim 17, wherein the treatment volume comprises a treatment tank, circulation chute or furnace.

34. (currently amended) Process for treatment of a liquid metal in a bath comprising injecting of a gas through a plurality of orifices in a substantially planar surface of a static gas injection device, the orifices being formed in a substantially planar surface without protuberances or discontinuities, and the planar surface being formed of a material wettable by the liquid metal and inert to the liquid metal, thereby forming bubbles of a diameter smaller than 20 mm with the liquid metal being at rest.

35. (previously presented) Process according to claim 34, wherein the bubble diameter is smaller than 10 mm.

36. (previously presented) Process according to claim 34, additionally comprising measuring bubble size by a method comprising irradiating the liquid metal bath into which the bubbles are emitted using X-rays, retrieving bubble images with a camera, displaying the bubble images and determining bubble size from the bubble images.

37. (currently amended) Process for the treatment of a liquid metal by injection of a gas, comprising injecting the gas through a device comprising at least one static injection part made of a material inert to the liquid metal and wettable by the liquid metal, the static part comprising a plurality of orifices disposed on a substantially planar surface without protuberances or discontinuities,

the wettable material and optionally orifice configuration being selected such that bubbles emitted by the device have a spreading ratio of less than 5.

38. (previously presented) Process according to claim 37, wherein the spreading ratio is less than 3.

39. (previously presented) Process according to claim 38, wherein the spreading ratio is less than 1.5.

40. (previously presented) Process according to claim 37, additionally comprising measuring bubble size by a method comprising irradiating the liquid metal bath into which the bubbles are emitted using X-rays, retrieving bubble images with a camera, displaying the bubble images and determining bubble size from the bubble images.

41. (new) Device according to claim 17, wherein the wettability of the surface by the liquid metal is the sole means of limiting spreading of bubbles emitted by the device.